

Surface modification of nano-TiN by using silane coupling agent

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Titanium nitride (TiN) nano-particles were subjected to graft modification by silane coupling agent (KH-570) via a direct blending method. The hydroxyl groups on the surface of TiN nano-particles can interact with silanol groups [–Si–OCH₃] of KH-570 forming an organic coating layer. The covalent bonds (Ti–O–Si) formation was testified by Fourier transform infrared spectra (FTIR) and X-ray photoelectron spectroscopy (XPS). Through transmission electron micrograph (TEM) observations, it was found that KH-570 could improve the dispersibility of nano-TiN particles in ethyl acetate. Thermo gravimetric analysis (TGA) and contact angle measurements indicated that KH-570 molecules were adsorbed or anchored on the surface of nano-TiN particle and the net efficiency of it was 22.76 %, which facilitated to hinder the aggregation of nano-TiN particles.

Keywords: nano titanium nitride; silane coupling agents; surface modification; dispersion

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1. Introduction

In recent years, nano-particles have received considerable attention for their special physical and chemical properties. However, inorganic nano-particles are very prone to agglomerate in media and show poor dispersion capacity in organic solvents and oil due to their high surface energy. Because of the inconsistent interfacial interaction, the combination of the inorganic nano-particles with the polymer matrix is weak, which limits the wide application of nano-particles [1-3]. How to disperse the inorganic nano-particles in organic polymer matrices and improve their interfacial interaction are the main issues to be solved. Fortunately, this problem can be resolved by using some special preparation techniques, for example, the preparation of nano-particles with surface modified by organic compounds. If the surface modification agents are high-weight hydrocarbons, the nano-particles can be dispersed stably in organic solvents and oil [4-6]. It has been reported that organic compound coatings on TiO₂, CeO₂, SiO₂ and Al₂O₃ have been synthesized successfully to improve their dispersive capacity in organic solvents and polymer matrices [7–12]. However, few of these papers have studied systemically the surface modification of nano-titanium nitride (TiN) with organic silane coupling agents.

TiN particles are widely used due to their superior properties, such as good wear resistance, high melting point (2950 °C), high hardness, high chemical and thermal stability, high corrosion resistance, high electrical and thermal conductivity (5 × 10⁴ Ω^{-1} cm⁻¹), biocompatibility and antimicrobial effect for medical devices and surgical tools [13–19]. γ -methacryloxypropyl trimethoxy silane (KH-570), as a silane coupling agent, is often used to modify the fillers such as ZnO, TiO₂, carbon fiber, and so on. When the modified fillers are introduced into a certain polymer matrix, the interface adhesion can be enhanced significantly [20–23].

In the present work, some silane coupling agents were found to make nano-TiN particles disperse well and steadily in many organic mediums. In order to further study the effect

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of coupling agent on the composite interface, KH-570 was used as a modifying agent to control the surface properties of nano-TiN particles. The structural changes of the modified nano-TiN (M-TiN) particles were characterized by Fourier infrared spectra (FTIR), X-ray photoelectron (XPS), spectroscopy transmission electron microscopy (TEM). Contact angle measuring instrument (CAMI) and thermogravimetric analysis (TGA) were also used in this experiment. On the one hand, the side groups $[-Si(OCH_3)_3]$ in the main chain of KH-570 may react with -OH, -NH and -NH₂ on the surface of the nano-TiN powder containing active hydrogen. On the other hand, KH-570 has a carbon chain structure and can provide great compatibility with organic solvents and polymer matrices. This paper attempts to characterize the performances of the M-TiN particles, and analyze the potential application of the M-TiN to materials. It can help to design high performance composite materials.

2. Experimental

2.1 Surface modification of nano-TiN

TiN nano-particles used in this experiment were commercial ultra-fine powders with the following characteristics: the average particle diameter -25.0 nm, the specific surface area $-115 \text{ m}^2\text{g}^{-1}$. All of the reagents were analytical-grade and used as received. Before modification, pristine TiN nano-particles were dried at 110.0 °C in a vacuum oven for 10 h to remove the moisture adsorbed on their surface. Then, TiN nano-particles (1.0 g) were dispersed in 150.0 ml ethyl acetate solvent by sonication, and 0.33 g of KH-570 was added. The mixture was refluxed at 75.0 °C for 3.5 h. After the reaction, the nano particles were separated by centrifuging, washed with ethyl acetate for some time and then dried at 50 °C for 24 h in a vacuum oven in order to remove the ethyl acetate.

2.2 Structural characterization

To evaluate the surface chemistry, FTIR spectra of nano-TiN and M-TiN were obtained with the use of a spectrometer (Nicolet Co., Nexus-870,

Fig. 1. FTIR spectra of (a) KH-570, (b) pristine nano-TiN, (c) M-TiN.

USA). The FTIR spectra were recorded using the potassium bromide pellets of the samples and analyzed from 400 cm⁻¹ to 4000 cm⁻¹ with a 4 cm⁻¹ resolution.

Composition of nano-TiN before and after surface modification was determined by XPS (VG Scientific Ltd., ESCALAB-MK-II, England) with Al K α X-ray (h ν = 1486.6 eV) at 15.0 kV and 150.0 W.

2.3 Particles characterization

TEM images were obtained to characterize the structures of samples. TEM observations of the samples morphology were performed using JEM-2100 TEM (JEOL, Japan) at 200 kV.

The contact angle was investigated using CAMI (Kino Co., SL 200C, USA) at the temperature of 25.0 °C. The surfaces of the samples were dropped by water and the angle value was taken as its contact angle.

The content of the intercalated modifier was determined by TGA with a thermal analyzer (Netzsch Co., STA449F3, Germany). Samples were heated to 600 $^{\circ}$ C from room temperature at a rate of 20 $^{\circ}$ C min⁻¹.



3. Results and discussion

3.1. Structural characterization

FTIR technique was used to show the structural changes in TiN nano-particles modified by coupling agent. Fig. 1 shows the FTIR spectra of pristine TiN and M-TiN modified with KH-570. The characteristic adsorption peaks of carboxyl (C=O) at 1720 cm⁻¹, -Si-OH at 1300 cm⁻¹, -Si-O-C at 1080 cm⁻¹ and -CH₃ in the region of $2800 - 3000 \text{ cm}^{-1}$ belong to KH-570 from Fig. 1a [12]. Fig. 1b and Fig. 1c show typical FTIR spectra of pristine and M-TiN particles modified with KH-570, respectively. Nano-TiN is highly reactive and easy to be oxidized upon exposure to air. So, the surface region of commercial nano-TiN particles has a large amount of Ti-NH₂, and Ti-OH groups. Fig. 1b shows the FTIR spectrum of pristine TiN; v_{O-H} and v_{N-H} combination bands can be seen at 3426 cm^{-1} [2]. The peak at 1635 cm^{-1} is assigned to the -NH shear vibration and the asymmetric stretching vibration of it is 1000 cm⁻¹, whereas the absorption peak near 600 cm^{-1} corresponds to the Ti–N absorption bands [24]. From the FTIR spectra of M-TiN, we can see that it is similar to that of KH-570. The absorption peaks at 2800 cm^{-1} , 3000 cm^{-1} , 1718 cm^{-1} , 1635 cm⁻¹, and 1000 - 1200 cm⁻¹ are attributed to the -CH₂-, -CH₃, C=O, C=C and Si-O groups, respectively. It can be found that the peak of Si-O is broader and stronger than that of the KH-570 in $1000 - 1150 \text{ cm}^{-1}$. This indicates that the surface group of nano-TiN has changed from Ti-OH to Ti-O-Si-C. The coupling agent is tightly adsorbed on the surface of the nano-TiN by chemisorption [2, 25, 26]. Although the FTIR spectra have unambiguously indicated the successful functionalization of KH-570 to the nano-TiN surface, the findings were additionally confirmed by XPS. Fig. 2 displays XPS spectra of nano-TiN after surface modification where the binding energy of C1s (284.9 eV) is used as the reference. The high resolution N 1s spectrum (Fig. 2A) of pristine nano-TiN occurs at 396.4 eV, which can be attributed to Ti-N component. The Ti spectrum displays four peaks at 563.1 eV, 458.4 eV, 60.5 eV and 36.2 eV, which can be ascribed to



Fig. 2. XPS spectra for (A) native TiN and (B) M-TiN particles.

Ti-O, Ti-N and Ti-N-O, respectively [15, 27]. The O and C spectra display peaks at 530.1 eV and 284.5 eV, which correspond to Ti-OH and surface contamination by carbon component of nano-TiN, respectively [28, 29]. In the XPS spectrum of M-TiN (Fig. 2B), in addition to nitrogen (N 1s 396.8 eV), titanium (Ti 2s 564.7 eV, Ti 2p 459.2 eV, Ti 3s 61.1 eV and Ti 3p 36.4 eV), carbon (C 1s 284.9 eV) and oxygen (O 1s 531.3 eV) photoelectron peaks, there are also silicon (Si 2s 153.0 eV and Si 2p 101.9 eV) photoelectron peaks [15]. The appearance of the peaks at 531.3 eV, 153.0 eV and 101.9 eV (corresponding to oxygen and silicon in Ti-O-Si) after surface modification indicates the chemical bonding between KH-570 and titanium oxide [30, 31].



Fig. 3. Ti 2p, N 1s and O 1s XPS fine scan spectra and the multiple sub-peaks of O 1s and Si 2p using Gaussian-Lorentzian fit for nano-TiN (A: pristine, B: modified)

Fig. 3 shows the Ti 2p, N 1s and O 1s peaks and the simultaneous splitting of C 1s core levels spectra. It can be found that the M-TiN's Ti 2p, N 1s and O 1s peak areas (content of carbon element), peak shapes and positions have changed, which reflects the chemical interaction between nano-TiN and graft KH-570. From Fig. 3, it can be seen that the typical O 1s spectra (at 531.8 eV and 530.1 eV) indicate that there are abundant oxygen of TiN or Ti–OH bonds in the unmodified nano-TiN samples. After being modified, the binding energy of the O 1s peak changes from 531.8 to 532.3 eV and 533.2 eV for Ti–O–Si. All data of XPS suggest that KH-570 covalently bonds to the surface of nanosized TiN particles and an organic coating layer is formed. This result is in agreement with that obtained from FTIR.

3.2. Particles characterization

Surface hydrophilicity of nano-TiN particles was investigated by contact angle measurements as shown in Fig. 4. After surface modification, the contact angle has increased from 21.15°



Fig. 4. Contact angle images of (A) nano-TiN and (B) M-TiN particles.



Fig. 5. TEM images for (a) nano-TiN and (b) M-TiN particles.

to 71.61° in water, which suggests that the surface hydrophobicity of nano-TiN nano-particles increased while the surface free energy of it decreased. These changes are likely to be due to the hydrophobic carbon backbone of the graft coupling agent [2, 32]. It can be inferred that after modification with KH-570, the nano-TiN particles can be dispersed in polymer materials easier than pristine nano-TiN particles. Thus, the M-TiN can be dispersed more easily in non-polar or weak polar polymer materials than pristine nano-TiN particles. Fig. 5 displays the TEM images of native nano-TiN and modified nano-TiN suspensions in ethyl acetate. In order to present detailed morphological information of the samples,



Fig. 6. TGA curves of (a) pristine nano-TiN and (b) M-TiN particles.

different magnifications are utilized for various samples. The obvious agglomerations can be seen in the images of native nano-TiN (Fig. 5a) and the homogeneous dispersion can be observed in the images of modified nano-TiN (Fig. 5b). This suggests that physical or chemical bonding occurs between the polar bonds of KH-570 and hydroxide groups of nano-TiN. The coupling agent chains grafted on the surface of nano-TiN cause mutual exclusion and steric hindrance effect. As a result, the surface free energy has been reduced correspondingly and the agglomeration is controlled. All the results further illustrate that KH-570 has played an important role in the dispersion of the nano-TiN particles.

3.3. Thermostability of n-TiN particles

Thermal stability of nano-TiN was measured by using TGA and the results are shown in Fig. 6. As shown in Fig. 6a, the thermal decomposition of pristine nano-TiN begins at about 180° C and the continuous mass loss can be observed from 180° C to 580 °C. This is likely to be due to a series of chemical reactions happening on the surface of the nano-TiN between surface groups or some physically and chemically adsorbed substances, followed by the desorption of H₂O, etc. [1, 12]. So, the mass loss of pristine nano-TiN is 1.38 %. The thermal degradation curve of nano-TiN modified with KH-570 is shown in Fig. 6b. The total weight loss of 8.89 %, from 180 °C to 580 °C can be attributed to the degradation of KH-570 and other adsorption substances on the surface. So we can get the net efficiency of the KH-570, which is calculated as follows:

net efficiency of the KH - 570 =
=
$$\frac{8.89 \ \% - 1.38 \ \%}{33 \ \%} \times 100 \ \% = 22.76 \ \% (1)$$

Therefore, it further illustrates that the KH-570 molecular chains are anchored or grafted on the surface of nano-TiN.

4. Conclusions

TiN nano-particles were modified by means of surface modification in situ where silane coupling agent (KH-570) was used as a modifier. The results show that the modifier has been adsorbed on the surface of nano-TiN particles by covalent bonds and changed the surface properties of the nano-TiN material. The M-TiN particles present superior dispersivity and stability in ethyl acetate than that of the untreated ones, and the net efficiency of KH-570 is 22.76 %.

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